

DOCKET NO: 247866US2S



IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :  
AKIRA HOKAZONO, ET AL. : EXAMINER: LOKE, S. H.  
SERIAL NO: 10/759,205 :  
RCE FILED: DECEMBER 29, 2005 : GROUP ART UNIT: 2811  
FOR: SEMICONDUCTOR DEVICE :  
HAVING METAL SILICIDE FILMS  
FORMED ON SOURCE AND  
DRAIN REGIONS AND METHOD  
FOR MANUFACTURING THE  
SAME

AMENDMENT UNDER 37 C.F.R. § 1.111

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated February 23, 2006, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 8 of this paper.